## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Application of:

Hatakeyama et al.

Group Art Unit: 1752

Serial No.:

09/994,808

Examiner: LEE, Sin J.

Filed: November 28, 2001

For:

AMINE COMPOUNDS, RESIST COMPOSITIONS AND PATTERNING PROCESS

## **REPLY**

Mail Stop Non Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SIR:

In response to the Office Action mailed on September 10, 2003, please amend the claims as follows and consider the remarks.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 13 of this paper.